

AMENDMENT UNDER 37 C.F.R. § 1.116
EXPEDITED PROCEDURE
GROUP 1752
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q54114

KAWABE, YASUMASA, et al.

Appln. No.: 09/295,329

Group Art Unit: 1752

Confirmation No.: 7050

Examiner: Y. THORNTON

Filed: April 21, 1999

For: **POSITIVE PHOTORESISTIVE RESIN COMPOSITION**

SUPPLEMENTAL AMENDMENT UNDER 37 C.F.R. § 1.116

ATTN: BOX AF

Commissioner for Patents
Washington, D.C. 20231

Sir:7

This Amendment is submitted in response to a telephone interview with Examiner Thornton in which the Examiner requested clarification of claims 23-25, as amended on December 10, 2002. A Petition for the fourth-month extension of time is being concurrently filed, making a response due on or before January 10, 2002. Please amend the above-identified application as follows:

IN THE CLAIMS:

Please enter the following amended claims:

Claim 24 (three times amended). A positive photosensitive resin composition comprising:

G1